

L Number	Hits	Search Text	DB	Time stamp
1	4	09/289514	USPAT	2004/08/17 10:35
2	4	09/289514 and (silicon or germanium or insulator or hydrogen or portion or relax or relaxed or bonded or entity or implanting or ion or substrate or glass or thickness or temperature or RTP or KeV or argon or helium or boron or bonding or ions)	USPAT	2004/08/17 10:52
3	1	("6750130").PN.	USPAT	2004/08/17 10:52
4	1	((("6750130").PN.) and (silicon or germanium or insulator or hydrogen or portion or relax or relaxed or bonded or entity or implanting or ion or substrate or glass or thickness or temperature or RTP or KeV or argon or helium or boron or bonding or ions)	USPAT	2004/08/17 10:52
-	6	(relaxed adj silicon adj germanium) and glass and hydrogen and temperature	USPAT	2004/08/16 17:03
-	1	("6689211").PN.	USPAT	2004/08/16 17:03
-	1	((("6689211").PN.) and (silicon or germanium or insulator or hydrogen or portion or relax or relaxed or bonded or entity or implanting or ion or substrate or glass or thickness or temperature or RTP or KeV or argon or helium or boron or bonding or ions)	USPAT	2004/08/17 10:34
-	1	("5891769").PN.	USPAT	2004/08/16 17:12
-	1	((("5891769").PN.) and (silicon or germanium or insulator or hydrogen or portion or relax or relaxed or bonded or entity or implanting or ion or substrate or glass or thickness or temperature or RTP or KeV or argon or helium or boron or bonding or ions)	USPAT	2004/08/16 17:14
-	0	("7603144").PN.	USPAT	2004/08/16 17:14
-	0	((("7603144").PN.) and (silicon or germanium or insulator or hydrogen or portion or relax or relaxed or bonded or entity or implanting or ion or substrate or glass or thickness or temperature or RTP or KeV or argon or helium or boron or bonding or ions)	USPAT	2004/08/16 17:14
-	1	("6703144").PN.	USPAT	2004/08/16 17:14
-	1	((("6703144").PN.) and (silicon or germanium or insulator or hydrogen or portion or relax or relaxed or bonded or entity or implanting or ion or substrate or glass or thickness or temperature or RTP or KeV or argon or helium or boron or bonding or ions)	USPAT	2004/08/16 17:15
-	1	("6713810").PN.	USPAT	2004/08/16 17:15
-	1	((("6713810").PN.) and (silicon or germanium or insulator or hydrogen or portion or relax or relaxed or bonded or entity or implanting or ion or substrate or glass or thickness or temperature or RTP or KeV or argon or helium or boron or bonding or ions)	USPAT	2004/08/16 17:16
-	1	("6759712").PN.	USPAT	2004/08/16 17:16
-	1	((("6759712").PN.) and (silicon or germanium or insulator or hydrogen or portion or relax or relaxed or bonded or entity or implanting or ion or substrate or glass or thickness or temperature or RTP or KeV or argon or helium or boron or bonding or ions)	USPAT	2004/08/17 10:35
-	349	438/311	USPAT	2004/08/17 09:09
-	237	438/473	USPAT	2004/08/17 09:10
-	357	438/663	USPAT	2004/08/17 09:10
-	1370	438/197	USPAT	2004/08/17 09:11
-	244	438/933	USPAT	2004/08/17 09:11
-	165	438/938	USPAT	2004/08/17 09:11

8/17/04